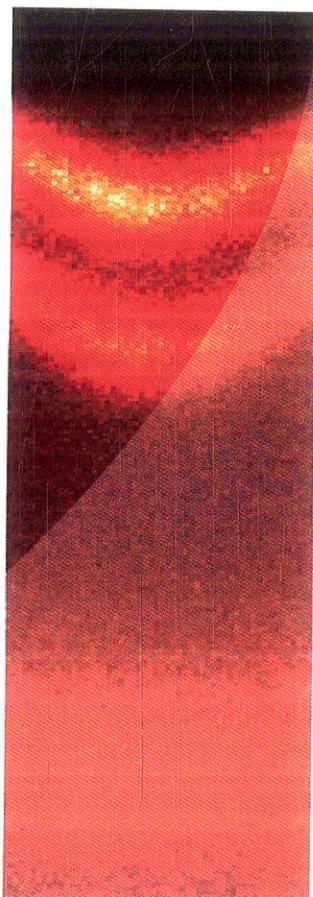
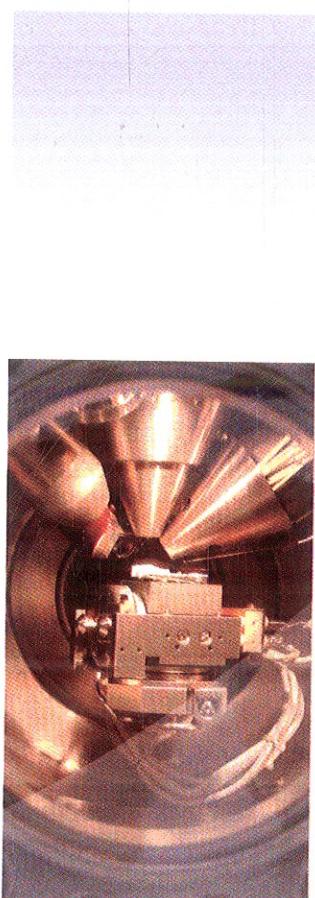
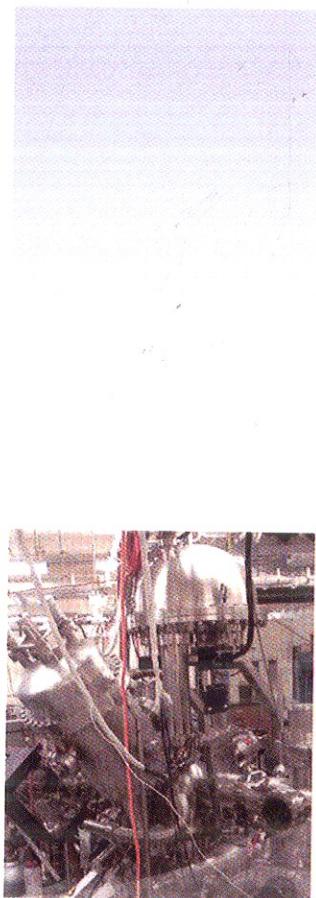


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Surface and Interface Science

Volume 1
Concepts and Methods



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